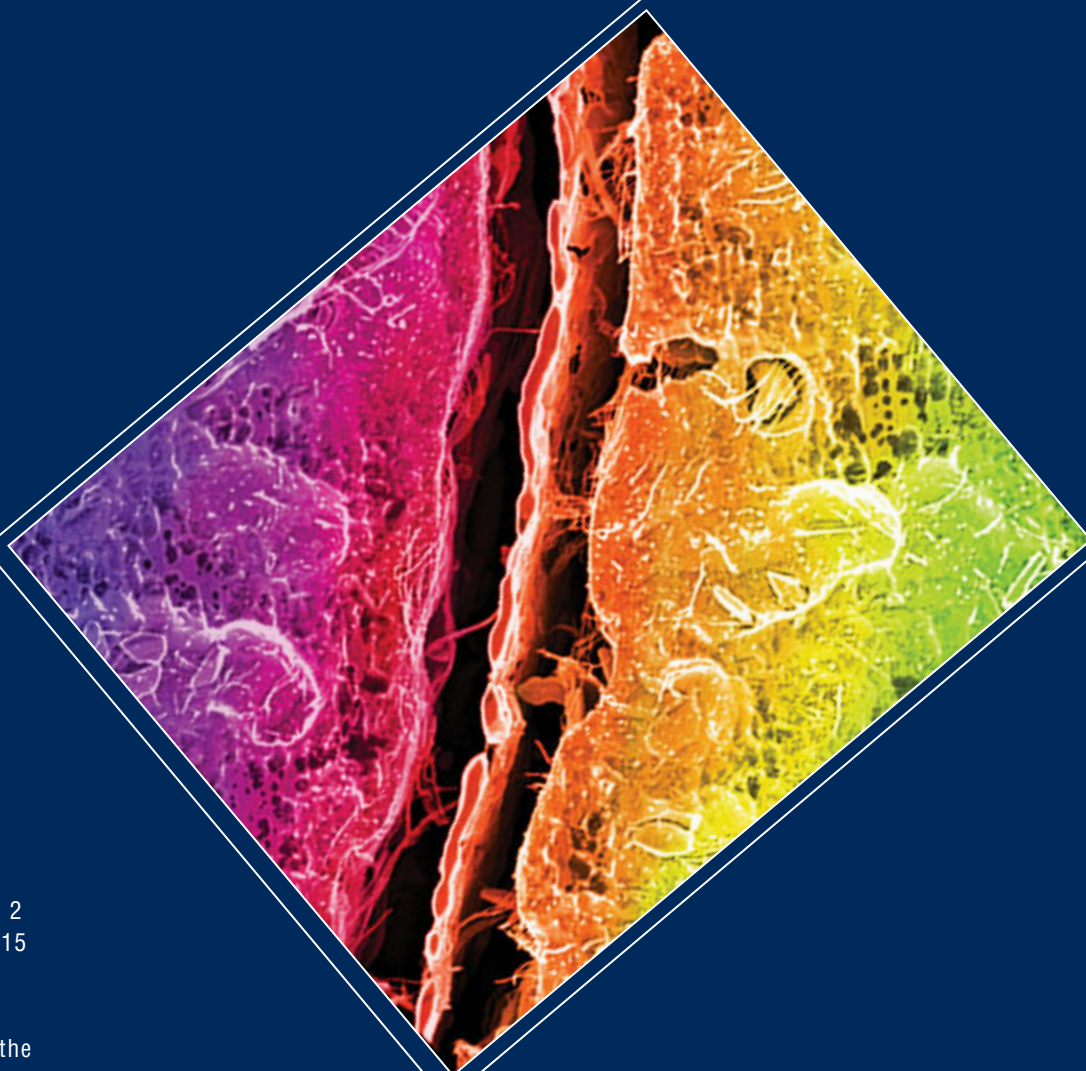


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 **Journal of  
MATERIALS RESEARCH**



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Cover: FIG. 8(g). High magnification corrosion morphology of the sample aged for 16 hours. [Z. Dong, Y. Liu, L. Yu, Y. Liu, and H. Li: Influence of aging on shape memory effect and corrosion resistance of a new Fe-Mn-Si-based alloy. p. 179].

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